



Molecular Imprints, Inc.

Contact Information:

Angela Ausman
Molecular Imprints, Inc.
1-512-334-1203
angela@molecularimprints.com

FOR RELEASE NOVEMBER 9

MOLECULAR IMPRINTS SELLS LITHOGRAPHY SYSTEM TO HP

AUSTIN, Texas, November 9, 2004 – Molecular Imprints, Inc. (MII), the leading manufacturer of Step and Flash Imprint Lithography (S-FIL™) equipment, continues to prove the capabilities of its technology with a sale of an Imprio™ 100 system to Hewlett-Packard (HP). The system delivers high resolution, sub-micron alignment, and 3-dimensional replication, to customers seeking cost-effective, sub-100nm lithography.

"We are very excited that HP is using our system for advanced designs," said Dr. Norman Schumaker, President and CEO of Molecular Imprints. "In addition to providing HP with the best technology, our goal is to now offer a roadmap for future products."

About Molecular Imprints Inc.

Molecular Imprints, Incorporated (MII) is developing and manufacturing nano-lithography systems for high resolution and for 3-dimensional pattern replication. The company has commercialized a new and unique Step and Flash Imprint Lithography technology (S-FIL), which is a simple step and repeat, room temperature, low pressure, nano-imprint process that has demonstrated 20 nanometer resolution. Molecular Imprints provides enabling lithography systems and technology for manufacturing applications in the areas of: nano-devices, micro structures, advanced packaging, bio-devices, optical components and semiconducting devices. For more information, visit: www.molecularimprints.com.

###